

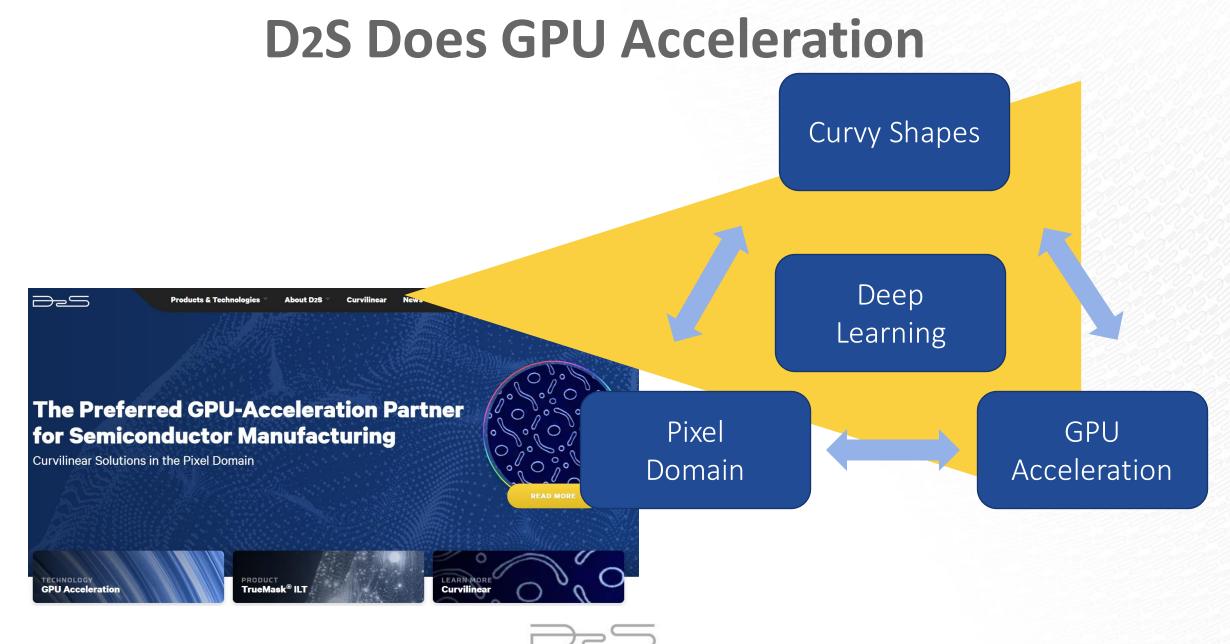


September 2022 | Aki Fujimura, CEO D2S, Inc.

O(p): GPUs, Pixels, DL, Curvy Masks & Designs

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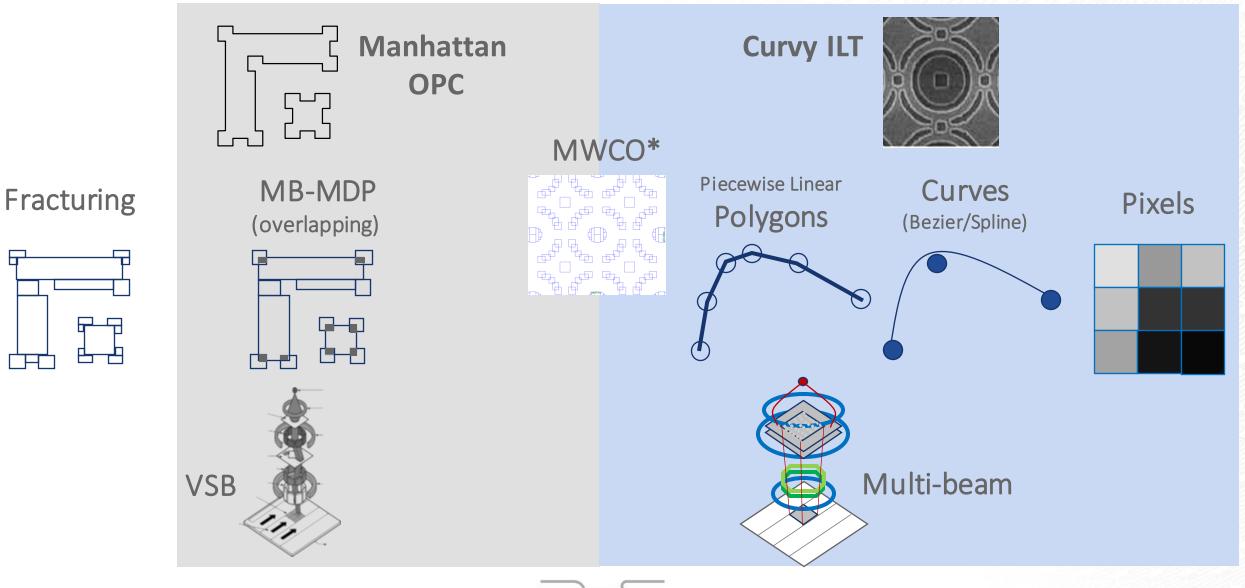




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GPU Accelerates Edge Manipulation, Too



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GPU is Great for Curvy



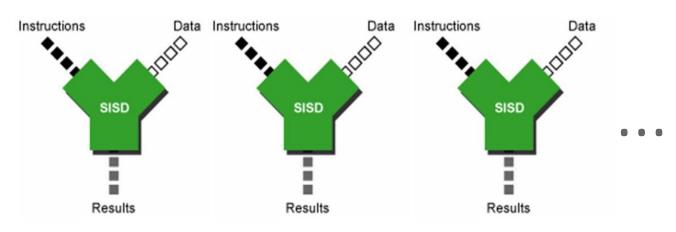
Because GPU is even better at pixels

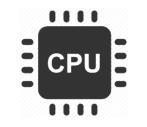


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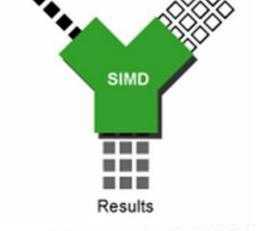
GPU is SIMD and SIMD is Great at Pixels





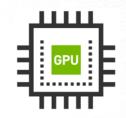
Multiple Single Instruction Single Data (SISD)





Data

Instructions

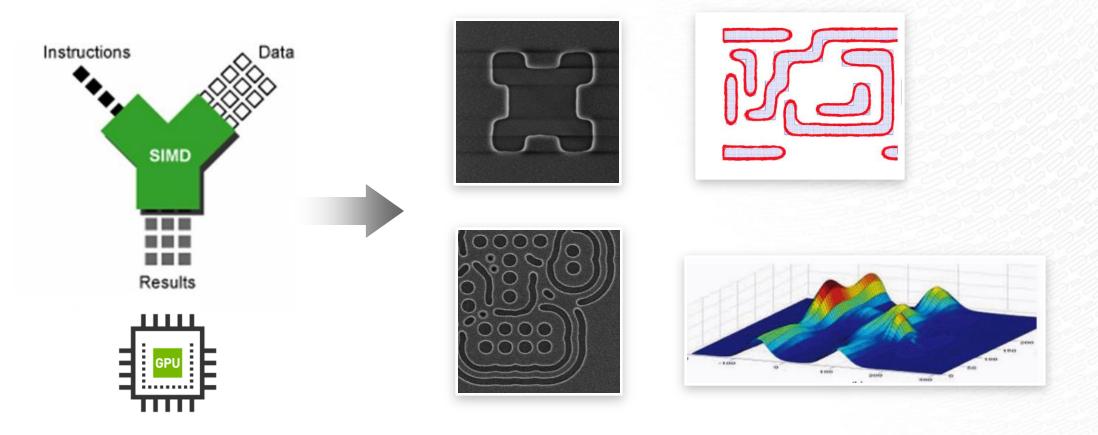


Single Instruction Multiple Data (SIMD)

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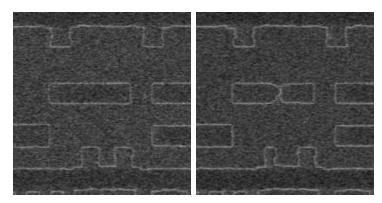
Mask and Wafer Effects are SIMD



Because nature is SIMD

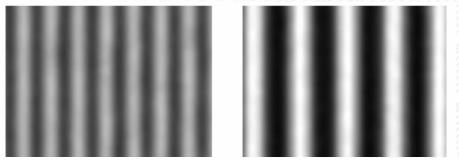


Image Processing is SIMD, Too



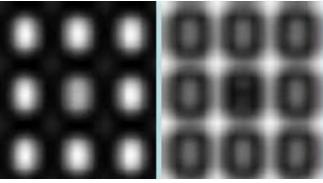
Source: NuFlare/CDLe

SEM



Source: Lasertec/BACUS Newsletter

Inspection



Source: L Pang, et al., "Expanding the applications of computational lithography and inspection (CLI) in mask inspection, metrology, review, and repair"

Because Images are Arrays of Pixels

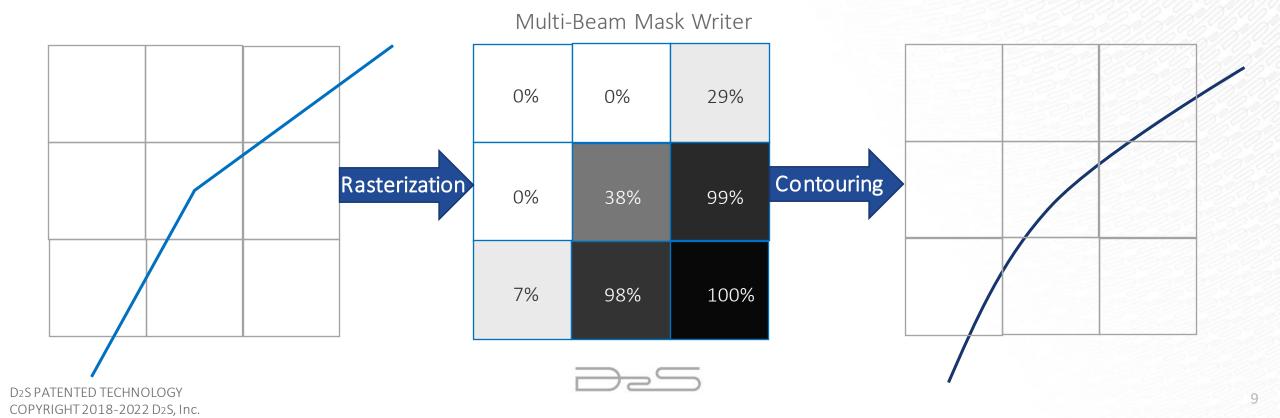


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Pixel-Based and Edge-Based are Duals

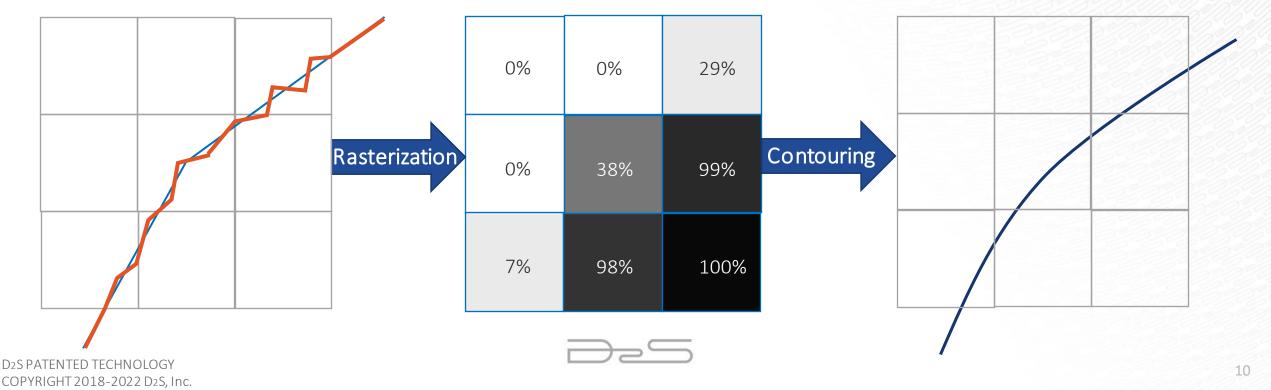
- Whatever you can do in one can be done in the other...given a resolution limit determined by "Nyquist"
- The only question is performance....





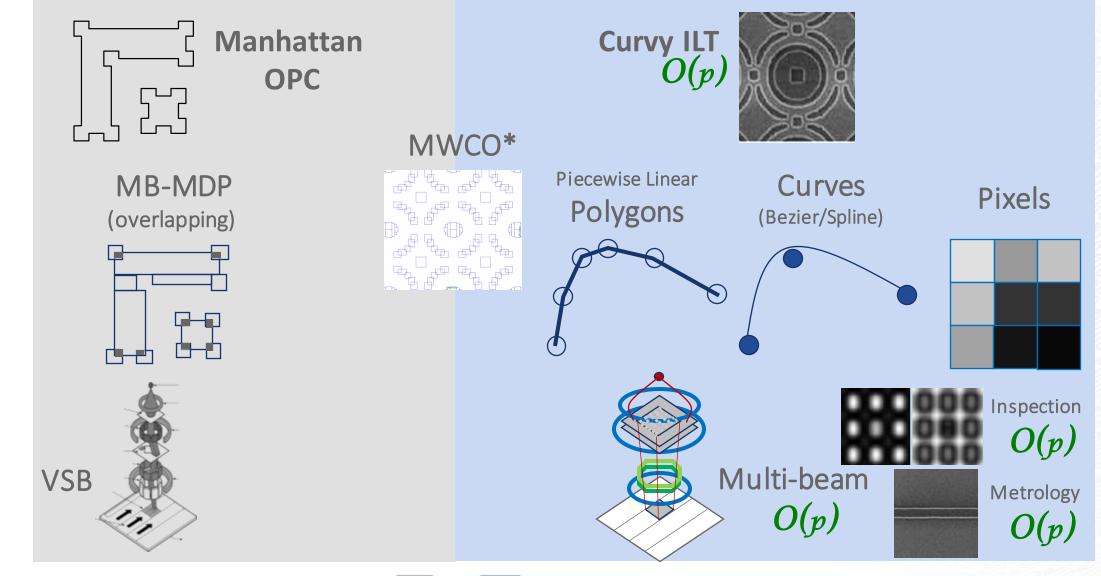
This Also Rasterizes Exactly the Same

- Rasterization is inherently a low-pass filter
- Red and blue become the same in pixels, but red uses much more data
- Curvilinear format would also become the same in pixels and thereafter
 - And represents the actual contoured shape that would be on the physical mask





Mask-Making is Already Pixel-Based

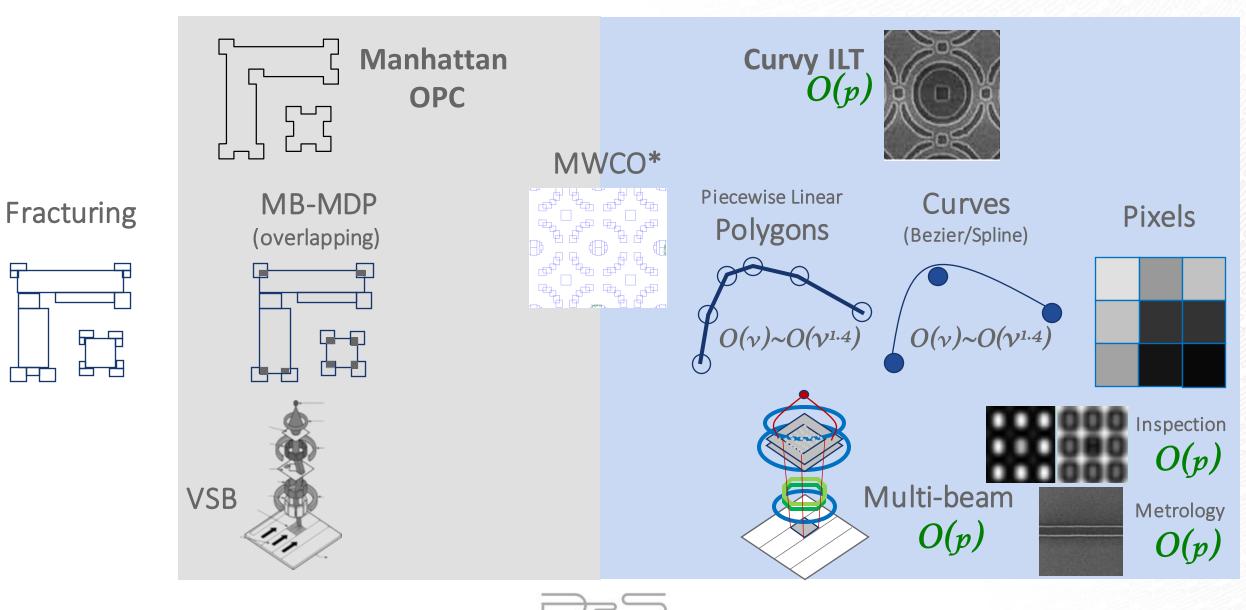


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Fracturing

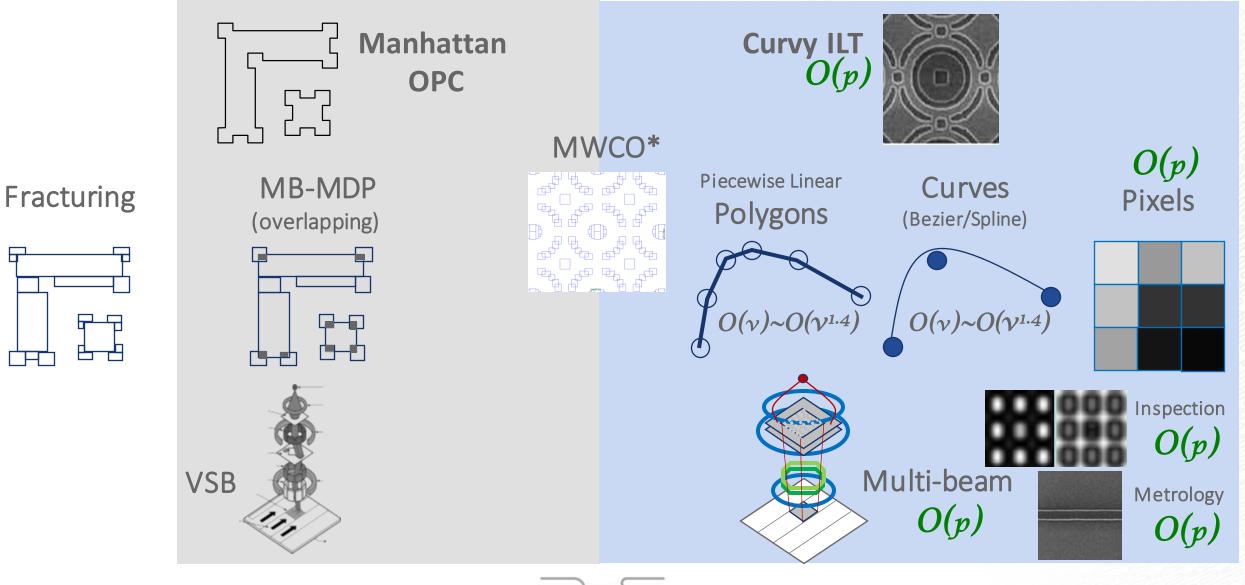


Datapath is Not



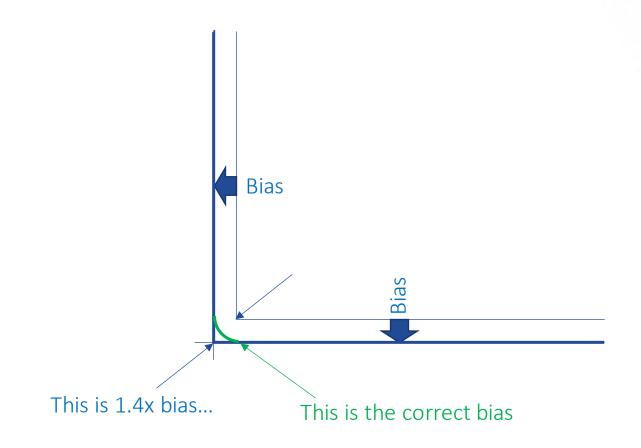


D2S is Adding a Pixel-Based Datapath





Edge or Pixel, Curvy Improves Manufacturing Simple example : Biasing



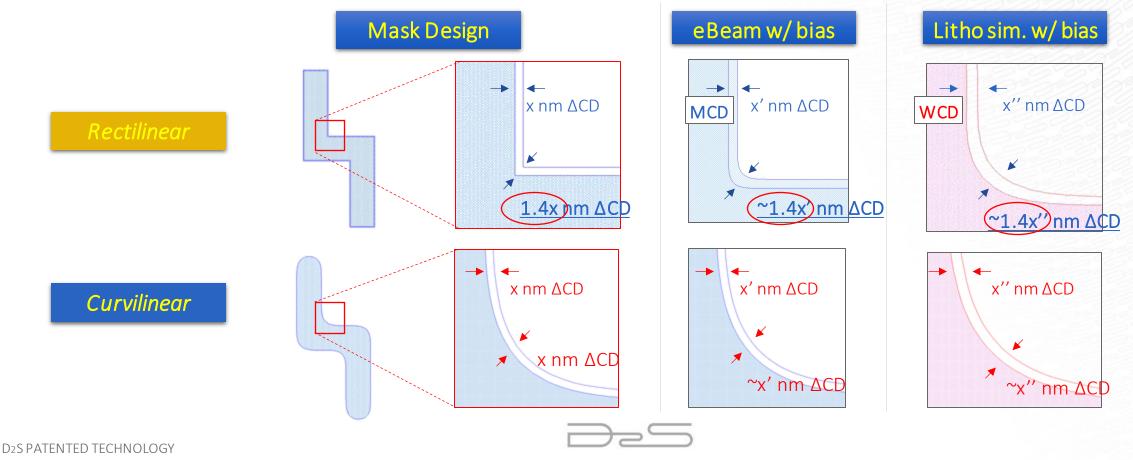
For traditional Manhattan edge-based CAD, it is bad to have bias create curvy shapes. So this is understandable but incorrect. Etching, for example, doesn't work that way.





Even a Simple Bias Operation is Better with Curvy

Rectilinear bias is off by 40% on corners

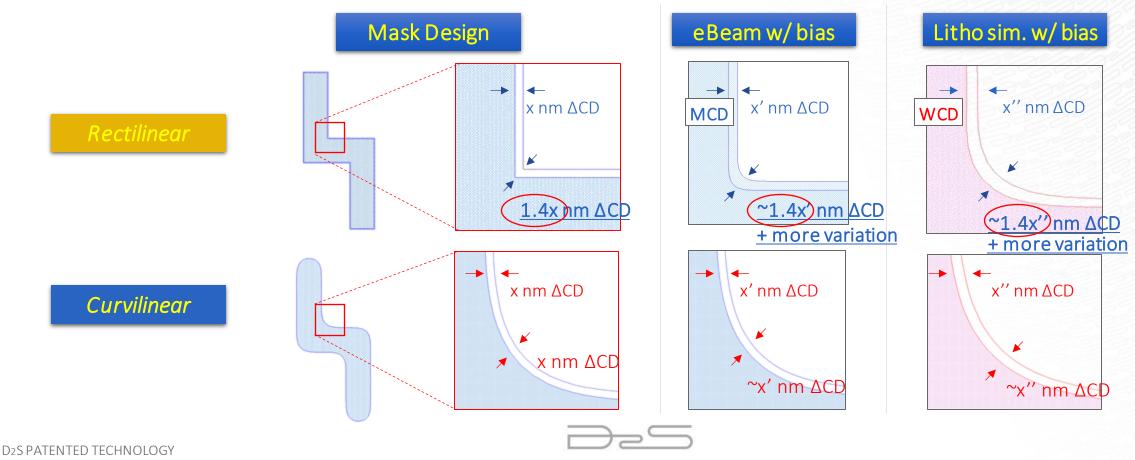


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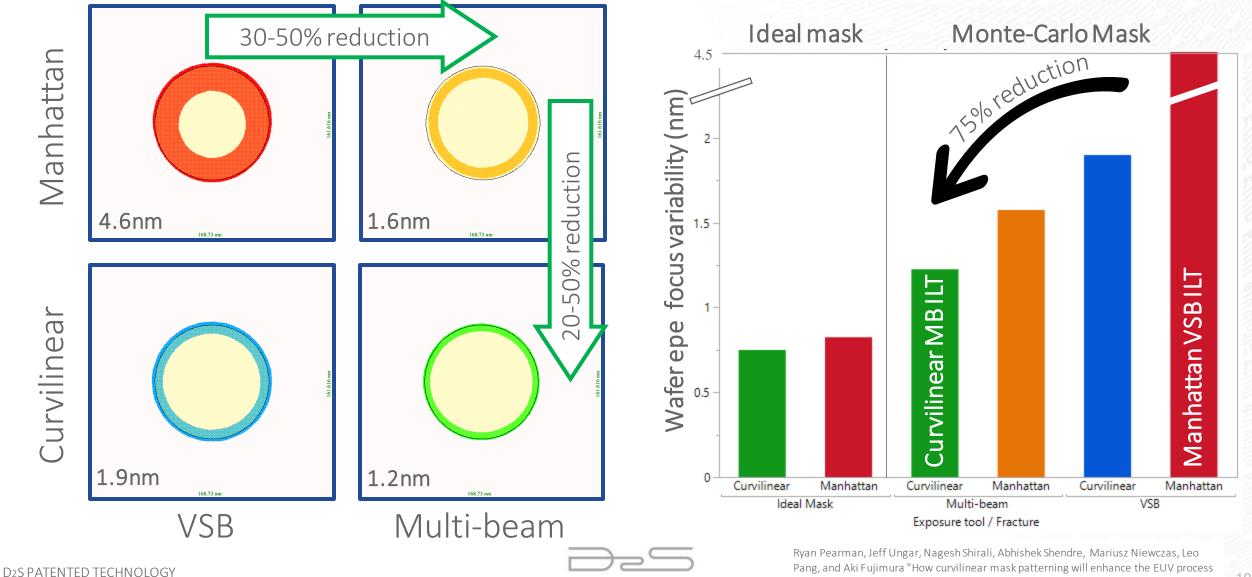
Even Worse is Manufacturing Variation

Dose margin is bad on 90° corners



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^{Beam} Manufacturable Shapes are More Reliably Manufacturable



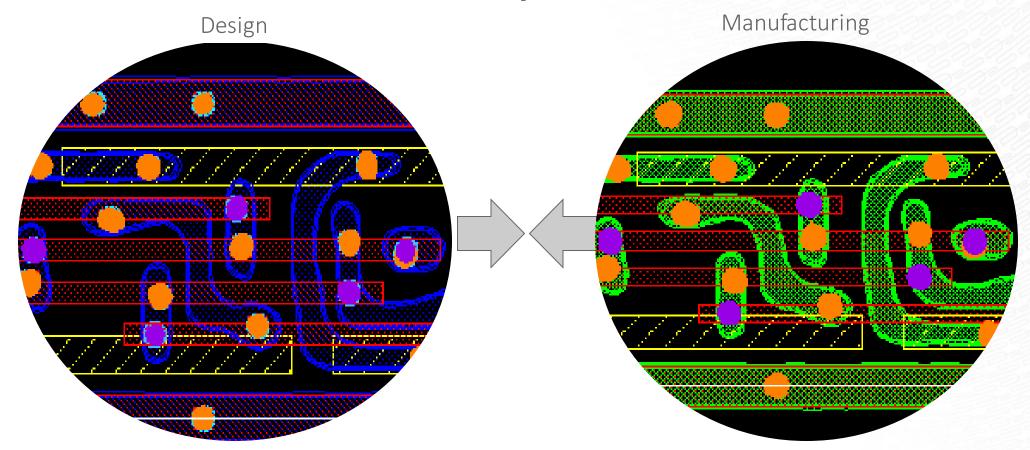
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Pang, and Aki Fujimura "How curvilinear mask patterning will enhance the EUV process 19 window: a study using rigorous wafer+mask dual simulation", Proc. SPIE 11178, (2019)



Manufacturable Shapes are More Reliably Manufacturable

On Wafer, too



First thing ILT does is to compute manufacturable curvy targets anyway





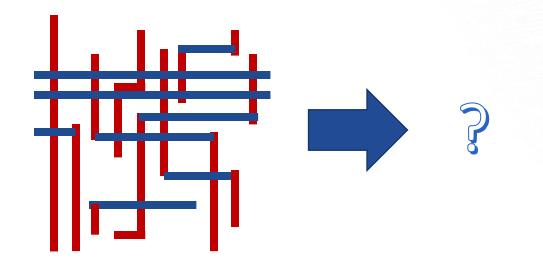
I Presented This at Design Automation Conference

"I was in EDA physical design since 1979 so I know it's important for you to know: Curvilinear Designs are Now Manufacturable. In fact, More Reliably Manufacturable."





Is it Time to Break the Manhattan Assumption?



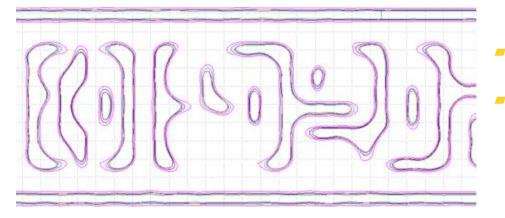
Most chips are interconnect-limited; Reducing vias will reduce routing congestion

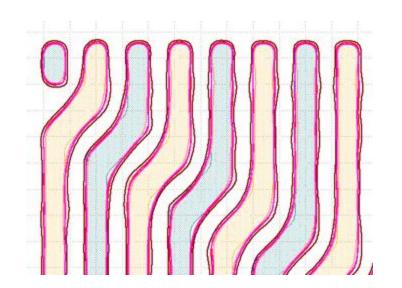
D2S PATENTE DITECHINO GOGY
CONFYREGHT 2018-2022 DESARC



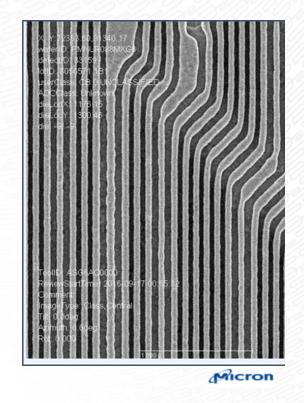


Curvy Designs are Better for Designers, Too



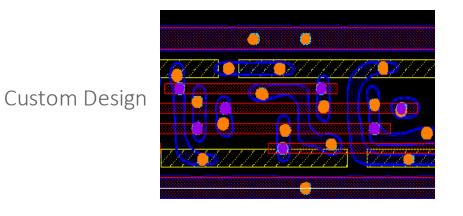


- Manufacturable Curvy Designs
- Improves, all at the same time
 - Yield
 - Power
 - Performance
 - Area
- The barriers are:
 - VSB mask writing
 - EDA infrastructure





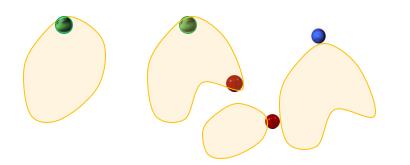
Actually: Only Routing plus Performance Improvements



Routing

Parasitic Extraction

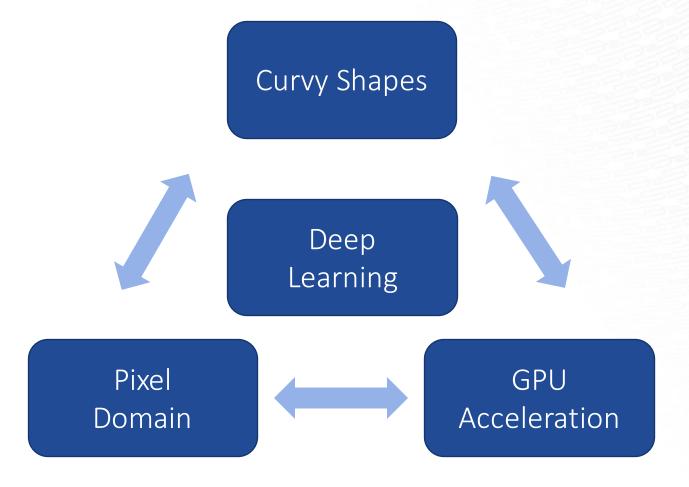








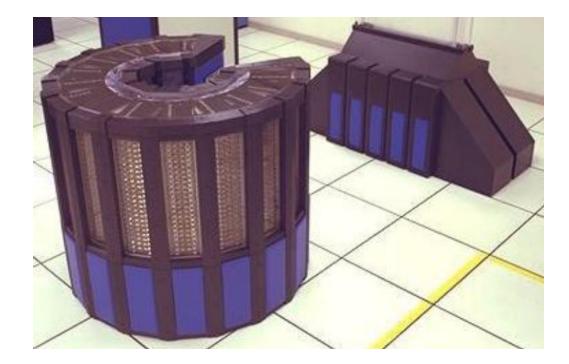
Curvy-Pixel-GPU Can Work for Them, Too





Today's GPU Workstation = 8,000 Cray-2s

60,000,000x Price Performance It's time to rethink EDA





Cray-2 (1985) 1.9 GFLOPS w/500MB @ \$15M

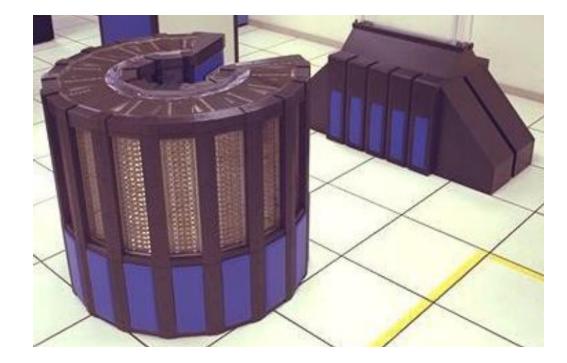


nVIDIA RTX 3090 Ti (2021) 15,300 GFLOPS w/24GB @ \$2,000



16,000? Today's GPU Workstation = 8,000 Cray-2s

150,000,000x? 60,000,000x Price Performance It's definitely time to rethink EDA





Announced Last Tuesday

Cray-2 (1985) 1.9 GFLOPS w/500MB @ \$15M



